Docket No.: N9460.0018/P018

(PATENT)

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of: Hisayuki Takasu et al.

Application No.: 10/705,845

Art Unit: 2851

Examiner: Della J. Rutledge Filed: November 13, 2003

For: METHOD OF DEVELOPING A RESIST

FILM AND A RESIST DEVELOPMENT

PROCESSOR

<u>AMENDMENT</u>

U.S. Patent and Trademark Office Customer Window, Mail Stop Amendment Randolph Building 401 Dulany Street Alexandria, VA 22314

Dear Sir:

Responsive to the Office Action dated June 29, 2005, please amend the abovereferenced application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 4 of this paper.